

## REMARKS

Applicants request favorable consideration and allowance of the subject application in view of the preceding amendments and the following remarks

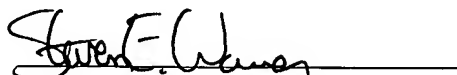
To place the application in better form, the specification has been amended to note its continuing status and to correct minor informalities. Also, a new title and abstract are presented in accordance with preferred practice. No new matter has been added by these changes.

Claims 14-19 are presented for consideration for consideration in lieu of claims 1-13, which have been canceled without prejudice or disclaimer. Claims 14 is the sole independent claim. Support for these claims can be found in the original application, as filed. Therefore, no new matter has been added.

Applicants submit that claims 14-19 patentably define features of the reflection type mask of the present invention. Applicants submit, therefore, that the instant application is in condition for allowance. Favorable reconsideration and an early Notice of Allowance are requested.

Applicants' undersigned attorney may be reached in our Washington, D.C. office by telephone at (202) 530-1010. All correspondence should be directed to our address listed below.

Respectfully submitted,

  
Attorney for Applicants  
Steven E. Warner  
Registration No. 33,326

FITZPATRICK, CELLA, HARPER & SCINTO  
30 Rockefeller Plaza  
New York, New York 10112-3801  
Facsimile: (212) 218-2200  
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